

INFORMATION DISCLOSURE STATEMENT

Atty. Docket No.: 150.0056 0104 Serial No.: Unassigned 12 57639

Applicant(s): Lee et al. Confirmation No.:

Filing Date: Herewith Group: 1765

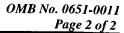
U.S. PATENT DOCUMENTS

Examiner Initial	Copy Enclosed	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
9 i		3,773,577	11/1973	Shibasaki et al.	216	106	
J.J.		4,528,066	07/09/85	Merkling et al.	438	721	
Yú		4,857,972	10/1989	Williams et al.	257	18	
Y C		4,875,973	10/1989	Heikkila et al.	216	107	
S		4,915,781	04/1990	Bohnen et al.	216	107	
do		5,010,032	04/23/91	Tang et al.	438	228	
90		5,047,367	09/10/91	Wei et al.		200	
4û		5,086,017	02/04/92	Lu	/38	586	
dil		5,163,259	11/10/92	Kolar et al.	437	192	
yo		5,198,382	03/30/93	Campbell et al.	437	46	
del		5,302,552	04/12/94	Duchateau et al.	437	250	_
9 e		5,482,895	01/09/96	Hayashi et al.	437	200	
90		5,510,292	04/23/96	Hayashi	438	720	
yo.		5,567,651	10/22/96	Berti et al.	438	303	
90		5,593,924	01/14/97	Apte et al.	437	200	
W		5,635,426	06/03/97	Hayashi et al.	438	453	
da		5,736,461	04/07/98	Berti et al.	438	651	
U)		5,880,033	03/09/99	Tsai	438	710	
de		5,919,311	07/1999	Shive et al.	134	1	
dû		5,454,901	10/1995	Tsuji	438	753	
40		4,316,765	02/1982	Thiel	438	હ	
Yu		5,780,363	07/1998	Delehanty et al.	43%	748	
Yû		5,486,266	01/1996	Tsai et al.	438	750	
45		5,858,861	01/1999	Weng et al.	438	750	
YIL I		6,074,960	08/20/1997	Lee et al.	438	749	/

EXAMINER Date Considered
4/1/02



^{*}Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.



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FOREIGN PATENT DOCUMENTS

Examiner	Сору	Document Number	Date	Country	Class	Subclass	Trans	lation
Initial	Enclosed						Yes	No
<u> </u>		NONE	•					

OTHER DOCUMENTS (Including Authors, Title, Date, Pertinent Papers, etc.)

	OTHER DOCUMENTS (Including Authors, Title, Date, Pertinent Papers, etc.)						
Examiner Initial	Copy Enclosed	Document Description					
de		Goto et al., "Optimization of Salicide Processes for sub 0.1-µm CMOS Devices", 1994 Symposium on VLSI Technology Digest of Technical Papers, pgs. 119-120 (1994).					
Ju		Ohguro et al., "Nitrogen-doped nickel monosilicide technique for deep submicron CMOS salicide", <i>International Electron Devices Meeting</i> , Washington, D.C., December 10-13, 1995, pgs. 10.3.1-10.3.4.					
							

EXAMINER	40	Date Considered 4/1/02
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